

Title (en)

HOT STAMPING MATERIAL AND PRODUCTION METHOD THEREFOR

Title (de)

HEISSPRÄGEMATERIAL UND VERFAHREN ZU SEINER HERSTELLUNG

Title (fr)

MATÉRIAUX D'ESTAMPAGE À CHAUD ET PROCÉDÉ DE FABRICATION ASSOCIÉ

Publication

**EP 4209610 A1 20230712 (EN)**

Application

**EP 21806609 A 20210608**

Priority

- KR 20200111293 A 20200901
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- KR 2021007161 W 20210608

Abstract (en)

Provided are a material for hot stamping, wherein the material includes: a steel sheet including carbon (C) in about 0.28 wt% to about 0.50 wt%, silicon (Si) in about 0.15 wt% to about 0.70 wt%, manganese (Mn) in about 0.5 wt% to about 2.0 wt%, phosphorus (P) less than or equal to 0.05 wt%, sulfur (S) less than or equal to 0.01 wt%, chromium (Cr) of about 0.1 wt% to about 0.5 wt%, boron (B) in about 0.001 wt% to about 0.005 wt%, an additive less than or equal to 0.1 wt%, balance iron (Fe), and other inevitable impurities; and fine precipitates distributed within the steel sheet, wherein the additive includes at least one of titanium (Ti), niobium (Nb), and vanadium (V), and the fine precipitates include nitride or carbide of at least one of titanium (Ti), niobium (Nb), and vanadium (V), and trap hydrogen.

IPC 8 full level

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**C22C 38/26** (2006.01); **C22C 38/28** (2006.01)

CPC (source: CN EP US)

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